

**Notice of References Cited**

Application/Control No.

10/529,234

Applicant(s)/Patent Under  
Reexamination  
WARD-CLOSE ET AL.

Examiner

CHRISTOPHER KESSLER

Art Unit

1793

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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*	B	US-4,390,368	06-1983	Houck, David L.	420/432
*	C	US-3,343,944	09-1967	JEAN-MARIE LOGEROT et al.	75/342
*	D	US-3,690,635	09-1972	Harker et al.	266/149
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**NON-PATENT DOCUMENTS**

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	V	"Production of Refractory Metal Powders" ASM Handbook vol. 7 (1998), pp. 188-201
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.